

Introduction

The mechanical properties of the new designed alloys are greatly influenced by the microstructure and the resulting phase relationships. The alloys' microstructures can be enhanced by controlling the atomic interdiffusion process of a system species. Therefore, the mechanical properties

can be predictable if the diffusion parameters are being known and controllable.

to understand the **†** order diffusion phenomena, diffusion couple technique with Boltzmann -Matano analysis are used to Figure 1: Boltzmann-Matano plane

measure the interatomic diffusion coefficients of the system components.

 $\check{D}(c)$ is the interdiffusivity at the composition C (cm²/sec), *t* is the annealing time (sec), *dc*/ dx is the slope at the composition C (at.%/ cm), and x is the layer thickness (cm)



identification

xdc = 0

 $\breve{D}(c^{\Phi}) = - \left(\begin{array}{c} xdc \end{array} \right) / (2t\partial c / \partial x)$

Motivation

Very few attempts were carried out to measure the atomic interdiffusion coefficients of the Mg and Nd atoms in the Mg-Nd binary system.

The available data from the literature showed inaccurate results because one of the intermediate phases was missing from the obtained diffusion couple.

Objectives

The main objective of this work is to provide information on the interdiffusion coefficients of Mg and Nd atoms at Boltzmann-Matano interface between the existing binary compounds in the Mg-Nd system. Furthermore, this work will provide information on the temperature-independent diffusion coefficient (D_0) and the activation energy for diffusion (Q_d) .

This information is necessary for practical applications such as solidification, precipitation, homogenization of alloys, recrystallization, grain boundary migration, creep-resistance enhancement, and joining processes.



Acknowledgments

The Authors acknowledge NSERC for the financial support of this project through MagNET network of excellence.



Assessment of Atomic Interdiffusion of Mg and Nd in the Mg-Nd system

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Figure 5: Mounted diffusion couple for WDS

The temperature-independent coefficient and the activation energy were concluded from the log (D) Vs. 1000/T charts.



